Supporting Information

MoO₃ nanosheet arrays as superior anode materials for Li-

and Na-ion batteries

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Fig. S1 The initial three CV curves of annealed CFC for (a) LIBs and (b) SIBs.



Fig. S2 Cyclic stabilities of MoO_3/CFC prepared under different annealing temperatures, MoO_3 power/CFC and annealed CFC for LIBs at a current density of 1 mA cm⁻².



Fig. S3 The SEM images for LIBs: (a) MoO₃ NSA/CFC and (b) MoO₃ powder/CFC after cycling 20 times at a current density of 1 mA cm⁻².



Fig. S4 LIBs: Cyclic stabilities of MoO₃ NSA/CFC at a current density of (a) 2 mA cm⁻² and (b) 5 mA cm⁻².



Fig. S5 Rate capability of annealed CFC without loading MoO_3 for (a) LIBs and (b) SIBs.



Fig. S6 The calculated specific capacity of MoO₃ NSA/CFC for (a) LIBs and (b) SIBs.

Calculations: The capacity of MoO₃/CFC is calculated by removing the contribution of pure CFC. Specifically, we calculate the specific capacity of MoO₃ NSA/CFC by using

$$SC_M = (AC_M - AC_C)/A_M$$

where SC_M is the specific capacity of MoO₃ NSA/CFC, AC_M and AC_C are the average area capacity of MoO₃ NSA/CFC and CFC, respectively, A_M is the mass loading of MoO₃ NSA/CFC. For example, the mass loading of MoO₃ NSA/CFC is 1.00 mg cm⁻², and the average area capacity of MoO₃ NSA/CFC is 4.48 mAh cm⁻² at 0.1 mA cm⁻² (Figure 4c). The average area capacity of CFC is 2.70 mAh cm⁻² at 0.1 mA cm⁻² (Figure S5). So, the average specific capacity of MoO₃ NSA/CFC at 0.1 mA cm⁻² for LIBs is calculated as 1780 mAh g⁻¹.



Fig. S7 Initial five discharge-charge curves of annealed CFC at 0.1 mA cm^{-2} for SIBs.



Fig. S8 SIBs: cyclic stabilities of MoO₃ NSA/CFC at a current density of 1 mA cm⁻².

Table S1. Comparison of MoO₃ based anode materials for LIBs

Active material	Current	Discharge	Charge	Initial	Reference
	density	capacity	capacity	CE(%)	
MoO ₃ NSA/CFC	0.1 mA cm ⁻²	2273 mAh g ⁻¹	1978 mAh g ⁻¹	87	This work
graphite@MoO ₃	60 mA g ⁻¹	385 mAh g ⁻¹			1
C-MoO ₃ nanobelts	0.1C	$\sim 1300 \text{ mAh g}^{-1}$	~1118 mAh g ⁻¹	~86	2
M0O ₃ /C	0.2C	945 mAh g ⁻¹	813 mAh g ⁻¹	86	3
α-MoO ₃ film	50 mA g ⁻¹	961 mAh g ⁻¹	1662 mAh g ⁻¹	58	4
MoO3 film/Ni foam	70 mA g ⁻¹	1286 mAh g ⁻¹			5
α-MoO ₃ /graphene	50 mA g ⁻¹	1406.8 mAh g ⁻¹	977.7 mAh g ⁻¹	70	6
MoO3 film/Ti foil	0.13C	980 mAh g ⁻¹			7
MoO ₃ /MWCNT	100 mA g ⁻¹	1685.4 mAh g ⁻¹	1028.3 mAh g ⁻¹	61	8
MoO ₃ /C nanobelts	100 mA g ⁻¹	1595 mAh g-1	1014 mAh g ⁻¹	64	9
MoO ₃ nanoflower	550 mA g ⁻¹	1432.5 mAh g ⁻¹	1019.6 mAh g ⁻¹	72	10
MoO ₃ /NC	0.3C	1610 mAh g ⁻¹	1359 mAh g ⁻¹	84	11
nanosheets					

HfO ₂ -coated MoO ₃	100 mA g ⁻¹	1728 mAh g ⁻¹	1120 mAh g ⁻¹	65	12
h-MoO3 nanorods	150 mA g ⁻¹	1418.3 mAh g ⁻¹	924.2 mAh g ⁻¹	65	13
C-MoO ₃ NRs	0.1C	897 mAh g ⁻¹			14
Mo-MoO ₃ -graphene	0.1C	1145 mAh g ⁻¹	754 mAh g ⁻¹	65	15
MoO ₃ /CNFs	500 mA g ⁻¹	1102 mAh g ⁻¹	716 mAh g ⁻¹	65	16
MoO ₃ /graphene	50 mA g ⁻¹	1548 mAh g ⁻¹			17

Table S2. Comparison of MoO3 based anode materials for SIBs

Active material	Current	Discharge	Charge	Initial	Reference
	density	capacity	capacity	CE(%)	
MoO ₃ NSA/CFC	0.1 mA cm ⁻²	1897 mAh g ⁻¹	1365.8 mAh g ⁻¹	72	This work
a-MoO3	0.1C	771 mAh g ⁻¹	410 mAh g ⁻¹	53	18
α-MoO ₃ nanobelts	100 mA g ⁻¹	545 mAh g ⁻¹	330 mAh g ⁻¹	61	19
MoO ₃ /rGO	0.2C	1061.2 mAh g ⁻¹	934.4 mAh g ⁻¹	88	20
MoO ₃ /graphene	50 mA g ⁻¹	365.4 mAh/g			21
a-MoO3	100 mA g ⁻¹	836 mAh g ⁻¹	344.5 mAh g ⁻¹	41	22
microrods					

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